

(19)



Europäisches Patentamt
European Patent Office
Office européen des brevets



(11)

EP 1 283 109 A2

(12)

EUROPEAN PATENT APPLICATION

(43) Date of publication:
12.02.2003 Bulletin 2003/07

(51) Int Cl.7: **B41J 2/16, B41J 2/14**

(21) Application number: **02255582.5**

(22) Date of filing: **09.08.2002**

(84) Designated Contracting States:
**AT BE BG CH CY CZ DE DK EE ES FI FR GB GR
IE IT LI LU MC NL PT SE SK TR**
Designated Extension States:
AL LT LV MK RO SI

(30) Priority: **10.08.2001 JP 2001243299**
25.07.2002 JP 2002216166

(71) Applicant: **CANON KABUSHIKI KAISHA**
Ohta-ku Tokyo 146-8501 (JP)

(72) Inventors:
• **Komuro Hirokazu**
Tokyo (JP)
• **Miyagawa Masashi**
Tokyo (JP)

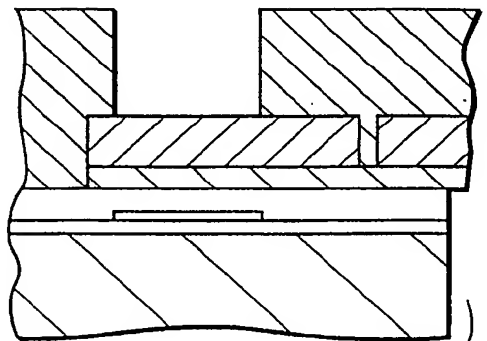
- **Misumi Yoshinori**
Tokyo (JP)
- **Kubota Masahiko**
Tokyo (JP)
- **Sugiyama Hiroyuki**
Tokyo (JP)
- **Inoue Ryoji**
Tokyo (JP)

(74) Representative:
Beresford, Keith Denis Lewis et al
BERESFORD & Co.
2-5 Warwick Court,
High Holborn
London WC1R 5DH (GB)

(54) **Ink jet recording head and method for manufacturing the same**

(57) The present invention provides a method for manufacturing an ink jet recording head utilizing ink bubbling by heating of an exothermic resistor to thereby eject ink and a method manufacturing the same, including the steps of: preparing a substrate provided with the exothermic resistor; applying such first resin on the substrate as to provide a first mold shape for forming the nozzle channel and the movable member; forming the first mold shape using the first resin; applying, on the substrate, second resin over the first mold shape for forming the nozzle channel and the movable member; and removing the first mold shape. By this method, the movable member is formed in the nozzle channel between the ink inlet and the exothermic resistor to thereby provide a high-density, high-accuracy ink jet recording head which can improve a frequency response while maintaining proper discharge performance.

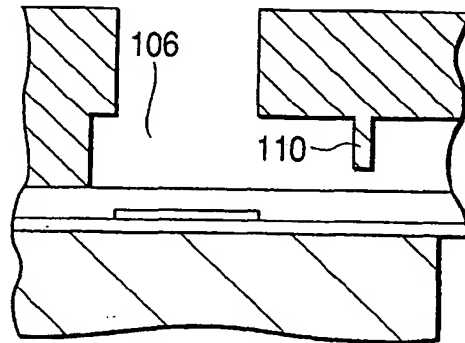
FIG. 4D



105

EP 1 283 109 A2

FIG. 5B



Description

BACKGROUND OF THE INVENTION

Field of the Invention

[0001] The present invention relates to an ink jet recording head for discharging a liquid from an orifice to form a droplet and a method for manufacturing the same.

Related Background Art

[0002] As for this type of an ink jet recording head for discharging a liquid from an orifice to form a droplet, an ink jet recording method disclosed in, for example, Japanese Patent Application Laid-Open No. 54-51837 has a different feature from the others in exerting thermal energy on the liquid to thereby obtain motive power for discharging the droplet.

[0003] That is, the recording method disclosed in this publication features that a liquid is heated when it receives an action of thermal energy to thereby produce a bubble, which in turn causes a droplet to be discharged from an orifice at the tip of a recording head section, which droplet then sticks to a recording medium to record information.

[0004] A recording head applied to this recording method typically comprises a liquid discharge section which includes as components an orifice from which a liquid is discharged and a thermal acting portion section which has a liquid channel to communicate with the orifice and at which thermal energy acts on the liquid to discharge a droplet, an exothermic resistor layer serving as a thermal converter, which is means for generating thermal energy, an overlying protection layer for protecting this exothermic resistor layer from ink, and an underlying layer for accumulating heat.

[0005] To improve a printing speed of such an ink jet recording head that obtains motive power for liquid discharge by exerting thermal energy on a liquid, its frequency response may be improved to solve the problem in performance. To improve the frequency response, it is necessary to improve ink refilling performance after droplet discharge. To improve the ink refilling performance, it is in turn necessary to reduce flow resistance over a passage from an ink inlet to an ink orifice.

[0006] If the flow resistance is reduced, however, a bubbling pressure escapes toward the ink inlet to result in a drop in discharge speed and so worsen stability, thus deteriorating the discharge performance hence printing. Accordingly, it has been difficult to improve the frequency response while maintaining the discharge performance at a proper level.

[0007] Furthermore, to meet a recent market desire for a higher image quality and so to achieve high-resolution printing by use of a small droplet, an ink jet print head needs to be arrayed to provide a high density and

also to fly a minute droplet from an orifice.

[0008] On the other hand, there has been made such a proposal for providing a movable member, which provides a so-called fluid diode, somewhere in a nozzle channel between the ink inlet and the orifice to thereby improve the frequency response while maintaining proper discharge performance. Such a conventional ink jet recording head, however, may sometimes be subject to flake-off or destruction of the movable member.

SUMMARY OF THE INVENTION

[0009] In view of the above, it is an object of the present invention to provide a high-density, high-accuracy, and highly reliable ink jet recording head which solves the above-mentioned problems to thereby enable forming a movable member in the nozzle channel between the ink inlet and the orifice, thus improving the frequency response while keeping proper discharge performance.

[0010] To this end, a method of the present invention for manufacturing an ink jet recording head having, on a substrate provided with an exothermic resistor, an ink orifice provided in correspondence to said exothermic resistor and a nozzle channel communicating with said ink orifice, with a movable member formed in said nozzle channel somewhere between said exothermic resistor and an ink inlet for supplying ink into said nozzle channel in such a configuration that a bubble generated in the ink in the nozzle channel by heat generated by said exothermic resistor is utilized to discharge the ink from said ink orifice, comprising the step of:

preparing the substrate provided with said exothermic resistor;
applying such first resin on said substrate as to provide a first mold shape for forming said nozzle channel and said movable member;
forming said first mold shape using said first resin;
applying on said substrate second resin over said first mold shape for forming said nozzle channel and said movable member; and
removing said first mold shape.

[0011] By this manufacturing method, the movable member can be molded at the same time as the nozzle mold shape and so can be formed together with the nozzle channel by photolithography at a high density and high accuracy, thus manufacturing a high density, high accuracy ink jet recording head.

[0012] Furthermore, to form the movable member, a mask pattern having a width less than a resolution limit of said first resin can be used to form such a portion of said first mold shape as to be used to form said movable member and use the resin applied on the portion later, thus forming the mold shapes of the nozzle channel and the movable member forming portion using the same mask. Accordingly, the nozzle channel and the movable

member can be formed at a mask formation accuracy. Furthermore, it is possible to eliminate one patterning step, thus reducing the costs.

[0013] Another ink jet recording head of the present invention for utilizing a bubble generated in ink in a nozzle channel when the ink is heated by an exothermic resistor, to discharge the ink from an ink orifice, comprising:

a substrate provided with said exothermic resistor; and
said nozzle channel formed on said substrate, with a movable member formed in said nozzle channel somewhere between said exothermic resistor and an ink inlet for supplying the ink into said nozzle orifice, said movable member having a supporting point thereof on such a wall of said nozzle channel as to be opposed to said substrate and a free end thereof on a surface of said nozzle channel on the side of said substrate and being formed integrally with said wall opposed to said substrate.

[0014] In this ink jet recording head, the same material can be used to form the ink channel and the movable member and integrally, so that it is possible to make this ink jet recording head highly reliable and this movable member difficult to flake off or destroy.

BRIEF DESCRIPTION OF THE DRAWINGS

[0015]

FIG. 1A is a schematic cross-sectional view for showing a method for manufacturing an ink jet recording head according to a first embodiment of the present invention, FIG. 1B is a cross-sectional view taken along line 1B-1B of FIG. 1A, FIG. 1C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 1A of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, and FIG. 1D is a cross-sectional view taken along line 1D-1D of FIG. 1C;

FIG. 2A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 1C of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, FIG. 2B is a cross-sectional view taken along line 2B-2B of FIG. 2A, FIG. 2C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 2A of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, and FIG. 2D is a cross-sectional view taken along line 2D-2D of FIG. 2C;

FIG. 3A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 2C of the method for manufacturing the ink jet recording

head according to the first embodiment of the present invention, FIG. 3B is a cross-sectional view taken along line 3B-3B of FIG. 3A, FIG. 3C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 3A of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, and FIG. 3D is a cross-sectional view taken along line 3D-3D of FIG. 3C;

FIG. 4A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 3C of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, FIG. 4B is a cross-sectional view taken along line 4B-4B of FIG. 4A, FIG. 4C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 4A of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, and FIG. 4D is a cross-sectional view taken along line 4D-4D of FIG. 4C;

FIG. 5A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 4C of the method for manufacturing the ink jet recording head according to the first embodiment of the present invention, FIG. 5B is a cross-sectional view taken along line 5B-5B of FIG. 5A.

FIG. 6A is a schematic cross-sectional view for showing a method for manufacturing an ink jet recording head according to a second embodiment of the present invention, FIG. 6B is a cross-sectional view taken along line 6B-6B of FIG. 6A, FIG. 6C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 6A of the method for manufacturing the ink jet recording head according to the second embodiment of the present invention, and FIG. 6D is a cross-sectional view taken along line 6D-6D of FIG. 6C;

FIG. 7A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 6C of the method for manufacturing the ink jet recording head according to the second embodiment of the present invention, FIG. 7B is a cross-sectional view taken along line 7B-7B of FIG. 7A, FIG. 7C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 7A of the method for manufacturing the ink jet recording head according to the second embodiment of the present invention, and FIG. 7D is a cross-sectional view taken along line 7D-7D of FIG. 7C;

FIG. 8A is a schematic cross-sectional view for explaining a step which follows the step of FIG. 7C of the method for manufacturing the ink jet recording head according to the second embodiment of the present invention, FIG. 8B is a cross-sectional view taken along line 8B-8B of FIG. 8A, FIG. 8C is a schematic cross-sectional view for explaining a step which follows the step of FIG. 8A of the method

of the ink jet recording head according to the third embodiment of the present invention;

FIG. 19A is a schematic cross-sectional view for showing an ink jet recording head according to a variant of a fourth embodiment of the present invention and FIG. 19B is a schematic cross-sectional view, taken along the line of 19B-19B in Fig. 19A, for showing a head chip obtained by the variant of the fourth embodiment of the present invention; FIGS. 20A and 20B are schematic cross-sectional views for explaining an operation of discharging ink droplets using the ink jet recording head of the present invention;

FIGS. 21A and 21B are schematic cross-sectional views which follow FIGS. 20A and 20B for explaining the operation of discharging ink droplets using the ink jet recording head of the present invention; and

FIG. 22 is a schematic perspective view for showing the ink jet recording head of the present invention.

DESCRIPTION OF THE PREFERRED EMBODIMENTS

[0016] The following will describe embodiments of the present invention. FIG. 22 shows a schematic perspective view of an ink jet recording head of the present invention. On a substrate 1 provided with an exothermic resistor 3 and an ink inlet 5 are formed a member 12 which makes up an ink channel and an orifice 7. Note here that in the following the cross-sectional views, illustrating methods for manufacturing ink jet recording heads in embodiments, of FIGS. 1A to 5B (first embodiment), FIGS. 6A to 9B (second embodiment), FIGS. 12A to 14C (third embodiment), and FIG. 15A to 17C (fourth embodiment) correspond to the cross-sectional view taken along line A-A' of FIG. 22.

First Embodiment

[0017] The following will describe a method for manufacturing the ink jet recording head according to the first embodiment of the present invention with reference to FIGS. 1A to 5B.

[0018] First, on a silicon substrate 101 are formed a heat accumulation layer 102 and $25\text{-}\mu\text{m} \times 25\text{-}\mu\text{m}$ heaters (exothermic resistors) 103 at 600 dpi, on which is formed a protection layer 104 (FIGS. 1A and 1B).

[0019] Next, a first mold resist 108 is applied to a thickness of $3\text{ }\mu\text{m}$ (FIGS. 1C and 1D).

[0020] Next, the first mold resist 108 is patterned into a shape of the nozzle channel by exposure and development (FIGS. 2A and 2B).

[0021] Next, on thus formed pattern is applied a second mold resist 109 to a thickness of $12\text{ }\mu\text{m}$ (FIGS. 2C and 2D).

[0022] Next, the second mold resist 109 is patterned into the nozzle channel shape and a movable member

shape 111 ($5\text{ }\mu\text{m} \times 25\text{ }\mu\text{m}$) by exposure and development (FIGS. 3A and 3B).

[0023] Next, a photosensitive epoxy material 112 is applied to form the nozzle channel, the orifice, and the movable member (FIGS. 3C and 3D).

[0024] Next, an orifice 107 is patterned to have a diameter of $18\text{ }\mu\text{m}$ by exposure and development (FIGS. 4A and 4B).

[0025] Next, an ink inlet 105 is formed by performing dry-etching on the substrate on its back face side (FIGS. 4C and 4D).

[0026] Finally, the resists which have served as mold shapes are etched off using an etchant to complete a head chip having the nozzle 106 with the movable member 110 formed therein (FIGS. 5A and 5B). Thus, the movable member formed in the nozzle channel has its supporting point on such a wall of the nozzle channel as to be opposite to a surface of the substrate on which the exothermic resistor is mounted and its free end on this side of the substrate.

[0027] Then, electrical mounting is carried out for feeding power to electrify the heater and tube in order to supply ink, thus completing the ink jet recording head.

[0028] Thus completed head has a high frequency response and good discharge performance. It is thus possible to print information speedily and satisfactorily.

[0029] Furthermore, since the movable member is patterned by photolithography, it can be formed highly accurately and also arranged with respect to the heater, the nozzle, and the orifice at a high accuracy. Accordingly, it is possible to sufficiently meet the requirements for the future smaller droplet and higher density.

[0030] Furthermore, the head can be manufactured integrally with the epoxy material of the nozzle and the orifice and so is not so subject to flake-off or destruction in long-term services nor to solving out or swelling of the epoxy material if it is selected to have ink resisting properties.

[0031] It is thus possible to provide a highly reliable head.

Second Embodiment

[0032] The following will describe another method for manufacturing an ink jet recording head according to the second embodiment of the present invention with reference to FIGS. 6A to 9B.

[0033] First, as in the case of the first embodiment, a substrate provided with heaters on which $25\text{-}\mu\text{m}$ by $25\text{-}\mu\text{m}$ heaters are arrayed is made (FIGS. 6A and 6B).

[0034] Next, a photo-resist 208 which provides a mold shape is applied to a thickness of $20\text{ }\mu\text{m}$ (FIGS. 6C and 6D).

[0035] Next, a pattern is formed through exposure and development by using a mask which has a mask pattern of a nozzle channel shape and a movable member shape such as shown in FIG. 10 (FIGS. 7A and 7B).

[0036] The photo-resist 208 used in the present em-

bodiment has a resolution of 4 μm when it is applied to a thickness of 20 μm , so that the mask used in this patterning is selected so that its width W at a portion that corresponds to a thickness of a movable member in the mask pattern may be 2 μm less than the resolution limit.

[0037] Such a mask as to have the width less than the resolution limit is used in formation to result in the resist being patterned halfway as shown in FIGS. 7A and 7B. The pattern, therefore, does not reach the substrate and so can function as a mold shape of the movable member.

[0038] Next, a photo-sensitive epoxy is applied to form a nozzle channel, an orifice, and the movable member (FIGS. 7C and 7D).

[0039] Next, the orifice is patterned to have a diameter of 18 μm by exposure and development (FIGS. 8A and 8B).

[0040] Next, dry-etching is conducted on the substrate on its back face side to form an ink inlet (FIGS. 8C and 8D).

[0041] Finally, the resist which has served as the mold shape is etched off using an etchant to complete the substrate provided with a nozzle (FIGS. 9A and 9B).

[0042] Then, a tube (not shown) for supplying ink and a printed wiring board (not shown) for feeding power to electrify the heaters are connected to the substrate, thus completing the ink jet recording head.

[0043] Thus completed head has a high frequency response and good discharge performance. It is thus possible to print information speedily and satisfactorily.

[0044] In addition to the effects of the first embodiments, the present embodiment can eliminate one of the application, exposure, and development steps for the mold resist, thus reducing the costs for manufacturing.

[0045] Furthermore, the nozzle channel and the movable member can be formed using the same mask, further improving accuracy in alignment.

[0046] Furthermore, the movable member thus formed in the nozzle channel is formed integrally with the wall of the nozzle channel as in the case of the first embodiment and also has such a construction that its supporting-point side thickness t_1 is larger than its free-end side thickness t_2 , thus making itself less subject to flake-off or destruction. It is thus possible to provide more highly reliable ink jet recording head.

[0047] Furthermore, as shown in FIG. 11, if the nozzle is patterned to form its channel in such a manner that part of the nozzle channel between the movable member and the inlet may be narrowed than the width of the movable member to thereby restrict the movable member from being displaced toward the inlet, the bubbling pressure can be suppressed more from escaping toward the inlet, thus manufacturing the head with even higher discharge performance without increasing the required steps in manufacture.

Third Embodiment

[0048] The following will describe a further method for manufacturing an ink jet recording head (ink jet print head) according to the third embodiment of the present invention with reference to FIGS. 12A to 14C.

[0049] First, as shown in FIG. 12A, for example, a silicon chip is mounted thereon by patterning etc. with a plurality of heaters 303 and a predetermined wiring (not shown) for feeding a voltages to these heaters 303, thus forming an element substrate 301. Then, as shown in FIG. 12B, on said element substrate 301 is applied to a thickness of about 5.0 μm a transparent negative-type resin layer 313 having the same composition as an orifice substrate 312 in order to form a projecting barrier 313' which restricts said movable member 310 from being displaced toward an inlet 305.

[0050] Then, as shown in FIG. 12C, UV rays are used to form the projecting pattern (projecting barrier) 313'. Next, as shown in FIGS. 12D and 12E, on said substrate 301 are applied an underlying resin layer 308 and an overlying resin layer 309 by spin coating consecutively. These underlying and overlying resin layers 308 and 309 are made of resin that can be resolved because its intra-molecular bond is destroyed when it is irradiated with Deep-UV rays (hereinafter called DUV rays), which are ultra-violet rays having a wavelength of 330 nm or less. Furthermore, by using resin which exhibits cross-linking properties due to dehydration/condensation as the material of the underlying resin layer, interactive melting of the underlying and overlying resin layers 308 and 309 can be prevented when the overlying resin layer 309 is applied by spin coating. As the material of the underlying resin layer 308, a solution has been used which is obtained, for example, by resolving, in a cyclohexanone solvent, binary copolymer (P(MMA-MAA)=90:10) polymerized by polymerizing radicals of methacrylic acid methyl (MMA) and methacrylic acid (MAA). As the material of the overlying resin layer 309, on the other hand, a solution has been used which is obtained, for example, by resolving poly-methyl isopropenyl ketone (PMIPK) in a cyclohexanone solvent. The binary copolymer (P(MMA-MAA)) used as the material of the underlying resin layer can be heated at a temperature of 180-200°C for 30 minutes to two hours to provide a harder cross-linking film owing to the dehydration/condensation reaction. Note here that although this cross-linking film is insoluble in a solvent, when irradiated with an electron beam such as DUV rays it decomposes and its mole molecular weight is decreased, so that only a portion thereof irradiated by the electron beam becomes soluble in the solvent.

[0051] Then, as shown in FIG. 13A, a filter which blocks DUV rays having a wavelength of less than 260 nm is mounted to an exposing apparatus for applying DUV rays to then use wavelength selecting means which transmits only such rays as to have a wavelength of 260 nm or more to thereby apply Near-UV rays (here-

inafter called NUV rays) having a wavelength nearly equal to 260 to 330 nm to the overlying resin layer 309 in order to expose and develop it, thus forming a desired nozzle pattern 309' by use of the overlying resin layer 309. Since the ratio in photosensitivity to NUV rays with a wavelength of about 260 to 330 nm is about 40:1 between the overlying and underlying resin layers 309 and 308, the underlying resin layer 308 is not exposed to the rays, so that the overlying resin layer: P(MMA-MAA) is not decomposed. Furthermore, the underlying resin layer 308 is made of a thermal cross-linkage film and so not resolved in a developer in the development of the overlying resin layer.

[0052] Then, as shown in FIG. 13B, the above-mentioned exposing apparatus is used to apply DUV rays with a wavelength of 210 to 330 nm to expose and develop the underlying resin layer, thus forming a desired nozzle pattern 308' by use of the underlying resin layer 308. The P(MMA-MAA) material used to form the underlying resin layer 308 has a high resolution and so can be formed so as to have a trench construction with a side wall inclination angle of 0 to 5° even if it is formed to a thickness of 5 to 20 μm or so.

[0053] Then, on the overlying and underlying resin layers 309 and 308 which have thus been made resolvable because the intra-molecular cross-linkage bond is destroyed by DUV rays with the nozzle patterns 308' and 309' formed thereon, a transparent covering resin layer 312 is applied which provides the orifice substrate 12 as shown in FIG. 13C.

[0054] Then, as shown in FIG. 13D, the exposing apparatus is used to apply UV rays to the covering resin layer 312 to expose and develop a portion that corresponds to an orifice 307 in order to etch it off, thus forming the orifice substrate. Preferably an inclination angle of a side wall of the orifice formed in this orifice substrate is nearly 0° with respect to the plane perpendicular to the main surface of said element substrate. Furthermore, as far as the inclination angle is 0 to 10°, the drop-let discharge properties are not so affected adversely.

[0055] Then, as shown in FIG. 14A, to protect the right side of the orifice plate in chemical etching, an organic resin film 314 is applied thereon. Then, as shown in FIG. 14B, chemical etching is conducted on the back side of the element substrate 301 to thereby form the inlet 305 therein. This chemical etching is of anisotropic processing by use of, for example, a strong alkali solution (KOH, NaOH, TMAH).

[0056] Then, as shown in FIG. 14C, DUV rays with a wavelength of 300 nm or less are applied from the main surface side of the element substrate 301 through the covering resin layer 312 to thereby solve out the overlying and underlying resin layers 309 and 308, which are the nozzle mold shape positioned between the element substrate 301 and the orifice substrate 312.

[0057] The movable member 310, therefore, is formed between the orifice 307 and the inlet 305 and also between the heaters 303 and the inlet 305 in the

supplying passage (nozzle channel) communicating the orifice 307 and the inlet 305 with each other, thus giving a chip provided with a nozzle channel 306 with a projecting barrier formed between the movable member 310 and the inlet 305 for restricting this movable member from being displaced toward the inlet. By electrically interconnecting this chip and a wiring board (not shown) which drives the heaters 303, the recording head is obtained.

[0058] Note here that by this method for manufacturing the recording head, furthermore, an overlying resin layer 41 and an underlying resin layer 42 made resolvable because DUV rays have been applied to destroy the intra-molecular cross-linkage bond can be stacked in construction with respect to the width direction of the element substrate 11, thus providing such a control section in the nozzle 27 as to have at least three steps. For example, even over the overlying resin layer can be formed a resin material which is photo-sensitive to lights having a wavelength of 400 nm or more, thus multi-stage nozzle construction.

Fourth Embodiment

[0059] The following will describe in detail a still further method for manufacturing the ink jet print head according to the fourth embodiment of the present invention with reference to FIGS. 15A to 17C.

[0060] First, as shown in FIG. 15A, a silicon chip is mounted thereon by patterning etc. with a plurality of electrical thermal converting elements (heaters) 403 and a wiring (not shown) necessary to drive these heaters, thus providing a substrate 401.

[0061] Then, as shown in FIGS. 15B and 15C, the substrate 401 is irradiated with DUV rays (ultraviolet rays having a wavelength of 300 nm or less) so that its intra-molecular cross-linkage bond may be destroyed and subsequently has resolvable resin layers 408 and 409 consecutively applied thereon by spin coating. In this step, thermal cross-linking type resin is used as a material of the underlying resin layer 408 to thus prevent interactive melting of the underlying and overlying resin layers when the overlying resin layer 409 is applied by spin coating. In this case, as a material of the underlying resin layer 408 is used a liquid obtained by resolving P (MMA-MAC=90:10) in a cyclohexanone solvent. As a material of the overlying resin layer, on the other hand is used a liquid obtained by resolving PMIPK in a cyclohexanone solvent. Then, an exposing apparatus (PLA521 made by Canon) using DUV rays is mounted with CM290 in order to use only the DUV rays having a wavelength of nearly 290 nm in the exposure and development of the overlying resin layer 409, thus forming a nozzle pattern 409' such as shown in FIG. 15D. In this case, since the ratio in photosensitivity to the DUV rays with a wavelength of nearly 290 nm is about 50:1 or more between the overlying resin layer 409 and the underlying resin layer 408, the underlying resin layer is not

exposed to the rays to be patterned. Next, the same exposing apparatus is mounted with CM250 to use only the DUV rays with a wavelength of nearly 250 nm in the exposure and development of the underlying resin layer, thus forming a nozzle pattern such as shown in FIG. 16A. Subsequently, on the resin layers 408 and 409 on which such nozzle patterns are formed and which have thus been made resolvable owing to the destruction of the intra-molecular cross-linkage bond is formed a covering resin layer 412 (FIG. 16B) such a portion of which as to correspond to an orifice 407 is exposed and developed using an exposing apparatus (MPA-600 made by Canon) using UV rays and removed (FIG. 16C).

[0062] Next, as shown in FIG. 17A, an organic resin film 414 is applied to protect the orifice face side in chemical etching. Then, as shown in FIGS. 17B and 17C for example, the substrate 401 is etched chemically on its back side to form the inlet 3. More specifically, a strong alkali solution (KOH, NaOH, TMAH) is used in anisotropic etching to thereby form an inlet 405. Finally, DUV rays (ultra-violet rays with a wavelength of 300 nm or less) are applied from the surface of the element substrate 401 through the covering resin layer 412 to thereby solve out the resin layers 408' and 409', which are the nozzle patterns. It is thus possible to give an ink jet head chip provided with the orifice 407, the inlet 405, a step-shaped nozzle 406 communicating with these, a movable member 410 between the electrical thermal converting element 403 in the nozzle 406 and the inlet 405, and a control section 412' which restricts the movable member from being displaced toward the inlet. By electrically connecting this chip with a wiring board which drives the electrical thermal converting element, the ink jet recording head of the present invention can be obtained.

[0063] FIG. 18 is a plan view of the nozzle portion of the above-mentioned ink jet recording head (FIG. 17C corresponds to a cross-sectional view taken along line 17C-17C of FIG. 18). The above-mentioned movable member 410 is formed by projecting part 412' of a side wall of the nozzle channel 406 by the stopper (barrier) which can restrict the movable member 410 from being displaced toward the ink inlet 405 in order to mostly enclose a portion extending from the movable member 410 to the orifice when a bubble is generated over the surfaces of the heaters. Preferably this barrier is small in size in order not to interfere with the flowing of ink from the inlet toward the orifice as much as possible when it is refilled. Furthermore, there is a minute gap that can be given by a photolithographic process also between the movable member and the nozzle wall. Preferably this gap is small in size as much as possible as far as it permits the movable member to be displaced.

[0064] Furthermore, as in the case of an ink jet recording head shown in FIGS. 19A and 19B, not only by projecting part 512' of a side wall of a nozzle channel 506 but also by forming between a movable member 510 and an ink inlet 505 as in the case of the present em-

bodiment but also by forming a projecting barrier 513' on the substrate as in the case of the third embodiment, it is possible to further suppress the flowing of the ink toward the ink inlet 505 using a movable member 510 more effectively when a bubble is growing, further improving the discharge performance.

[0065] The following will briefly describe the operations of thus manufactured ink jet recording head (liquid discharge head) of the present invention with reference to FIGS. 20A and 20B.

[0066] First, as shown in FIG. 20A, an orifice channel extending from the heaters to the orifice and a nozzle 606 extending from the heaters to the ink inlet are combined to form an L-shape. In the nozzle, the movable member is arranged perpendicularly to a surface of the substrate provided with the heaters on the side of the nozzle. As shown in FIG. 20B, on the other hand, when a bubble 615 is generated by the heaters, a pressure wave occurs simultaneously and ink starts to flow, to cause a movable member 610 to be inclined slightly toward an ink inlet 605, so that the nozzle is kept in a roughly enclosed state over a portion thereof from the orifice to the movable member by the movable member, a projecting barrier 613 formed on the HB (substrate), and a stopper-shaped structure 612' formed behind the movable member. It is thus possible to focus the pressure over the heaters mostly on the side of the orifice in order to thereby fly an discharged ink droplet 616 effectively. Note here that preferably a minute gap which is present between the movable member and a projecting barrier 613' is small in size as much as possible in order to give the above-mentioned roughly enclosed state. Furthermore, there is another minute gap also between the movable member 610 and the side wall of the nozzle 606.

[0067] Now, as shown in FIG. 21A, since the nozzle is roughly enclosed by the movable member 610, the projecting barrier 613', and the stopper-shaped structure 612', the bubble grows larger toward the orifice to thereby enable flying the ink droplet 616 from the orifice in more stable manner and more effectively. As shown in FIG. 21B, subsequently, when the bubble starts disappearing over the heaters, the movable member 610 starts to be displaced toward the orifice 607. Then, the movable member 610 is displaced greatly toward the orifice. In this case, a displacement of the movable member toward the orifice is larger than that thereof toward the ink inlet at the time of bubble growing. The ink is thus refilled speedily into a plurality of the ink nozzles 606 from the ink inlet 605. Note here that the ink is inhibited from flowing toward the inlet 605 when the bubble is generated by the movable member 610, the projecting barrier 613' formed on the HB (substrate) 601, and the stopper structure 612' formed behind the movable member, so that the quantity of the ink refilled into the nozzles 606 can be reduced to a minimum nearly equal to the volume of the ink flown.

Claims

1. A method for manufacturing an ink jet recording head having an exothermic resistor, an ink orifice provided in correspondence to said exothermic resistor, and a nozzle channel communicating with said ink orifice, with a movable member formed in said nozzle channel somewhere between said exothermic resistor and an ink inlet for supplying ink into said nozzle channel in such a configuration that a bubble generated in the ink in said nozzle channel by heat generated by said exothermic resistor is utilized to discharge the ink from said ink orifice, comprising the step of:
 - preparing a substrate provided with said exothermic resistor;
 - applying such first resin on said substrate as to provide a first mold shape for forming said nozzle channel and said movable member;
 - forming said first mold shape using said first resin;
 - applying, on said substrate, second resin over said first mold shape for forming said nozzle channel and said movable member; and
 - removing said first mold shape.
2. The method according to claim 1, wherein:
 - said first resin is a photo-resist; and
 - said step of forming said first mold shape includes a step of using a mask pattern having a width not larger than a resolution limit of said photo-resist to thereby form said movable member of said first mold shape.
3. The method according to claim 1, wherein:
 - said step of applying said first resin is preceded by a step of applying a third resin which provides a second mold shape used to form said nozzle channel on said substrate; and
 - said step of applying said first resin involves applying said first resin on said substrate in such a manner as to cover said second mold shape.
4. The method according to claim 1, wherein said step of applying said first resin is preceded by a further step of forming a projecting barrier at a corresponding position between said movable member and said inlet on said substrate.
5. An ink jet recording head utilizing a bubble generated in ink in a nozzle channel when the ink is heated by an exothermic resistor, to discharge the ink from an ink orifice, comprising:
 - a substrate provided with said exothermic resistor; and
 - said nozzle channel formed on said substrate, wherein a movable member is formed in said nozzle channel somewhere between said exothermic resistor and an ink inlet for supplying the ink into said nozzle orifice, said movable member having a supporting point thereof on such a wall of said nozzle channel as to be opposed to said substrate and a free end thereof on a surface of said nozzle channel on the side of said substrate and being formed integrally with said wall opposed to said substrate.
6. The ink jet recording head according to claim 5, wherein said wall and said movable member are made of resin.
7. The ink jet recording head according to claim 5, comprising a restricting section between said movable member in said nozzle channel and said ink inlet, for restricting said movable member from being displaced toward said ink inlet.
8. The ink jet recording head according to claim 7, wherein said restricting section is a projecting barrier provided on said substrate.
9. The ink jet recording head according to claim 7, wherein said restricting section is part of a member which makes up an inner side wall of said nozzle channel.
10. An ink jet recording head having an exothermic resistor, an ink orifice provided in correspondence to said exothermic resistor, and a nozzle channel communicating with said ink orifice, with a movable member formed in said nozzle channel somewhere between said exothermic resistor and an ink inlet for supplying ink into said nozzle channel in such a configuration that a bubble generated in the ink in said nozzle channel by heat generated by said exothermic resistor is utilized to discharge the ink from said ink orifice,
 - wherein said movable member is arranged perpendicularly to a surface of a substrate provided with said exothermic resistor on the side of said nozzle channel and has a supporting point thereof on such a surface of said nozzle channel as to be opposed to said substrate and a free end thereof on a surface of said nozzle channel on the side of said substrate.
11. The ink jet recording head according to claim 10, comprising a restricting section between said movable member in said nozzle channel and said ink inlet, for restricting said movable member from being displaced toward said ink inlet.

12. The ink jet recording head according to claim 10, wherein a displacement of said movable member toward said ink inlet is smaller than a displacement thereof toward said ink orifice.

5

13. A method of manufacturing an ink jet recording head having an ink channel with an ink ejection outlet, the ink channel containing a heat generating element and a movable member for causing ink to be supplied from the ink ejection outlet in response to generation of a bubble by heat supplied by the heat generating element, the method comprising:

10

providing a substrate carrying the heating element;

15

providing a masking layer on the substrate; patterning the masking layer to providing a mask region for defining an ink channel wall and the movable member;

providing a further layer on the masking layer to form the ink channel wall and the movable member; and

20

removing the masking layer to provide the ink channel.

25

30

35

40

45

50

55

FIG. 1A

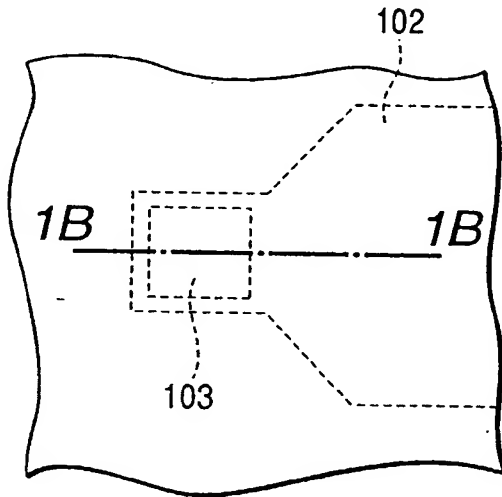


FIG. 1B

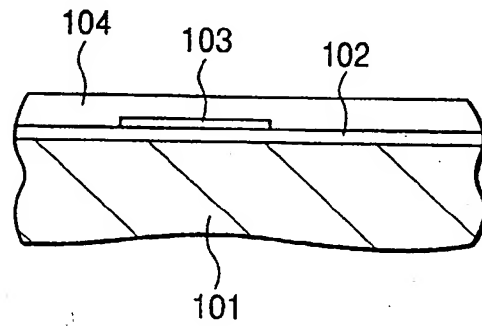


FIG. 1C

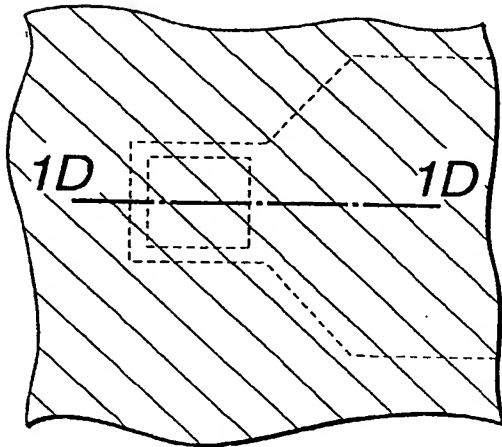


FIG. 1D

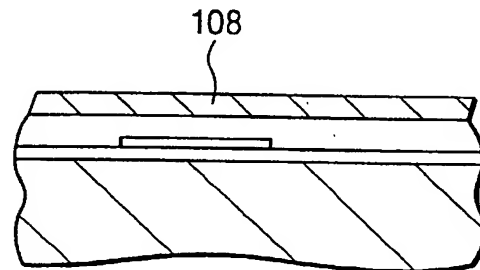


FIG. 2A

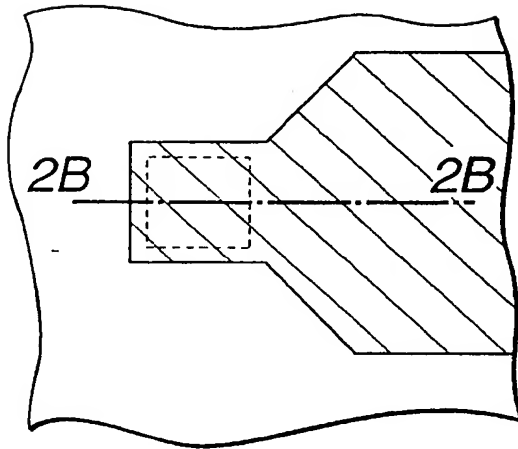


FIG. 2B

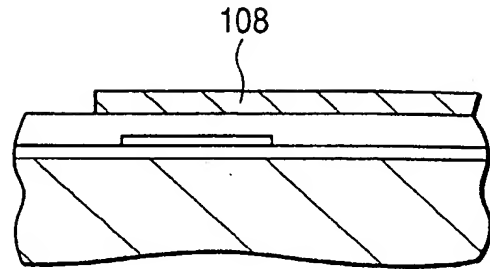


FIG. 2C

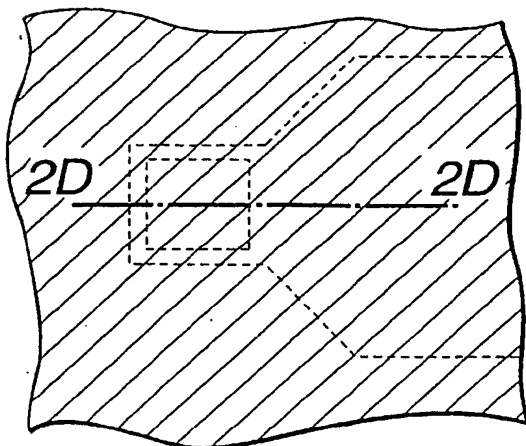


FIG. 2D

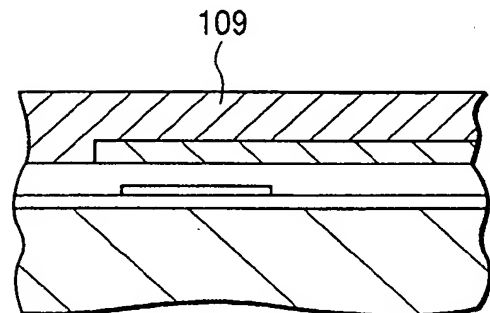


FIG. 3A

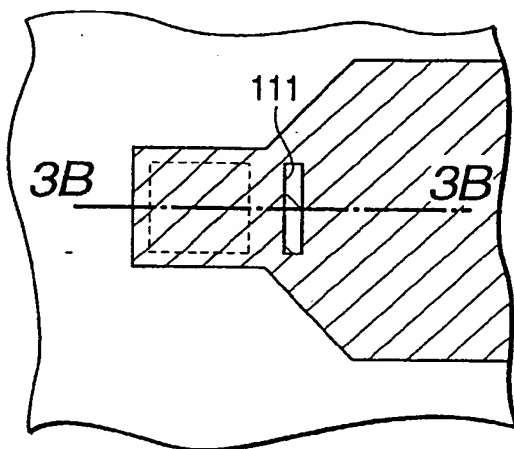


FIG. 3B

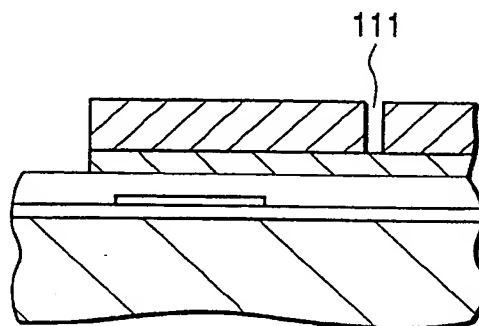


FIG. 3C

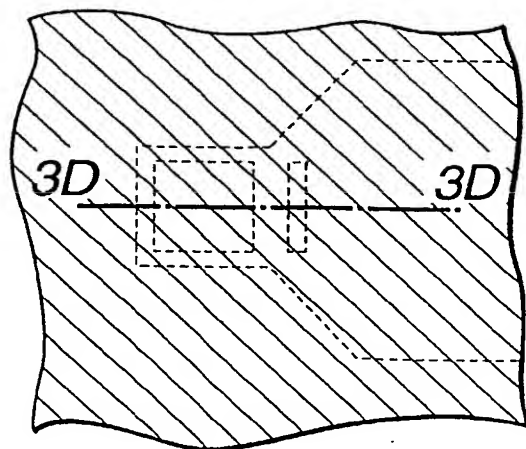


FIG. 3D

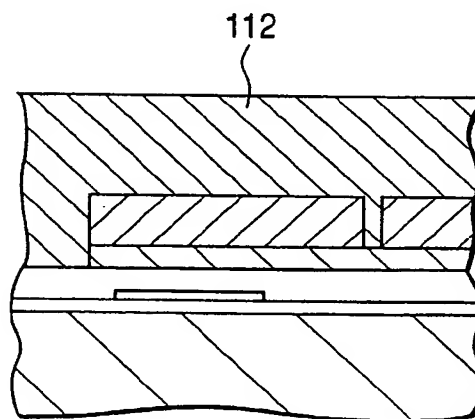


FIG. 4A

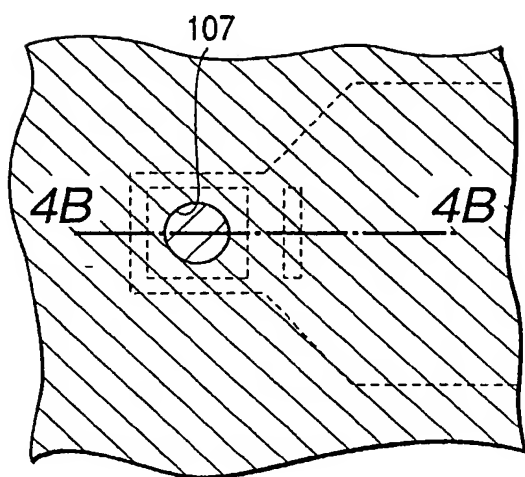


FIG. 4B

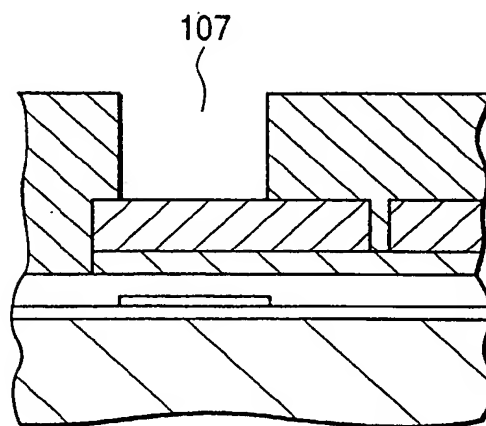


FIG. 4C

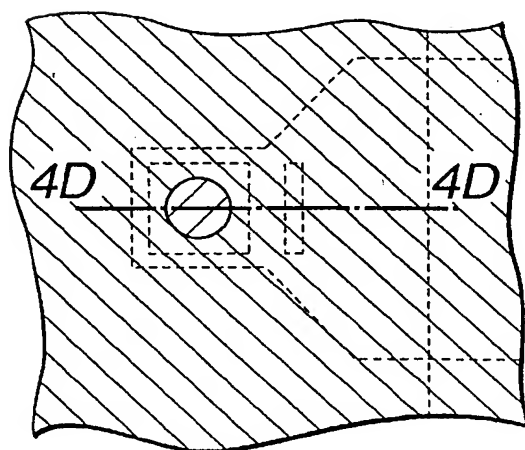


FIG. 4D

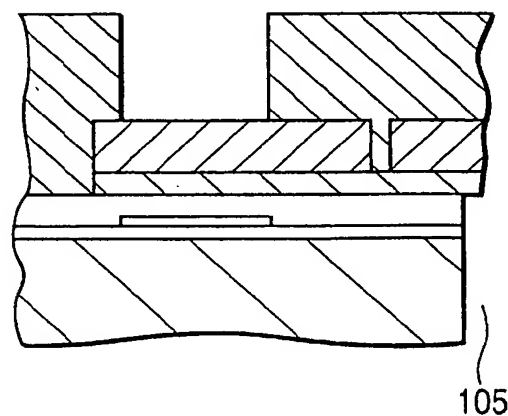


FIG. 5A

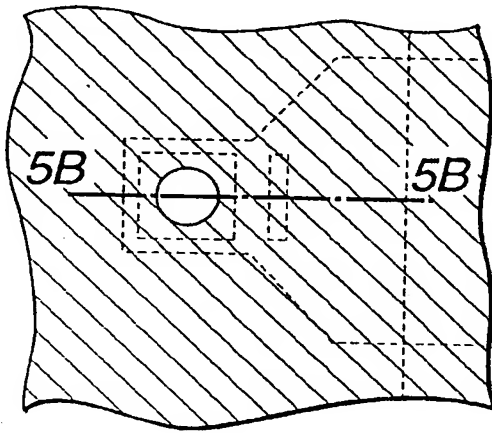


FIG. 5B

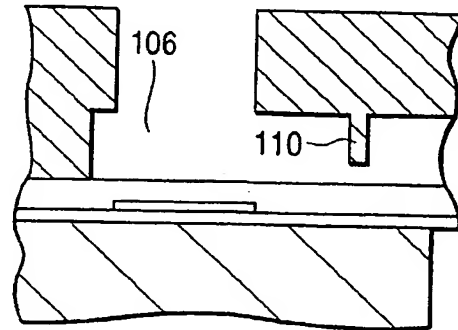


FIG. 6A

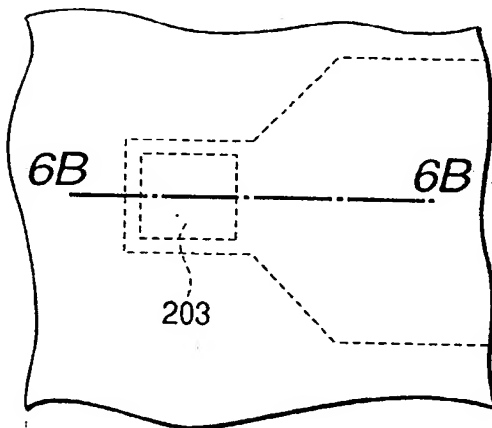


FIG. 6B

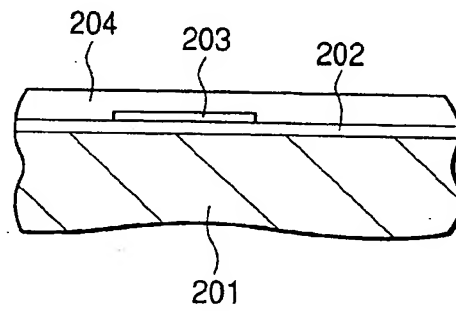


FIG. 6C

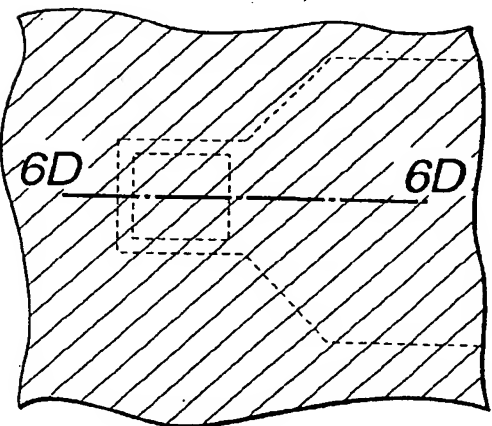


FIG. 6D

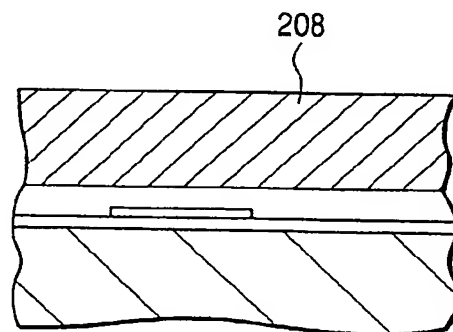


FIG. 7A

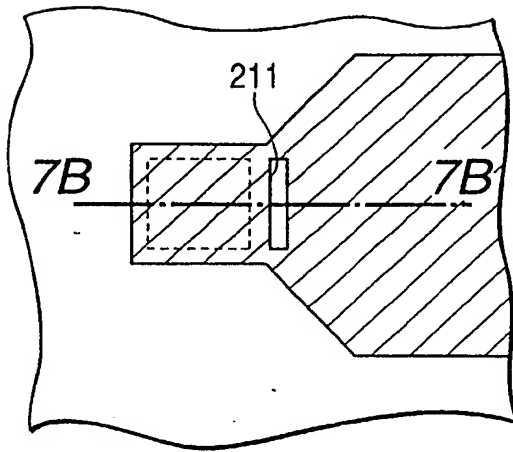


FIG. 7B

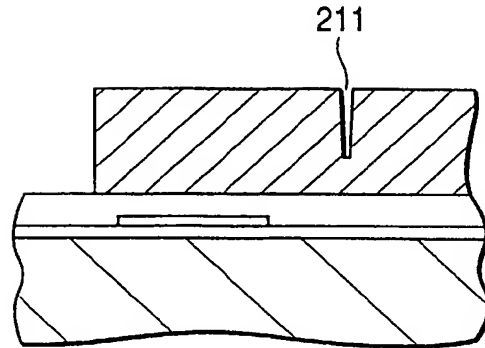


FIG. 7C

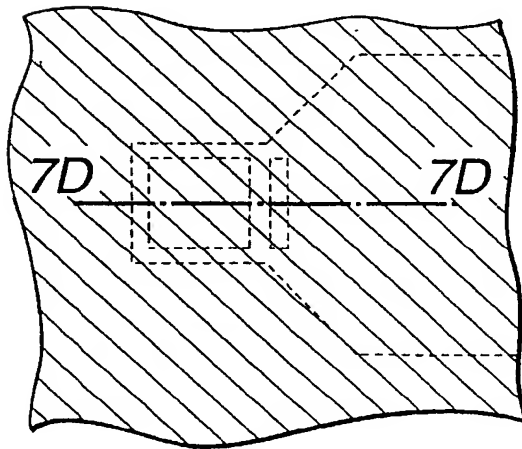


FIG. 7D

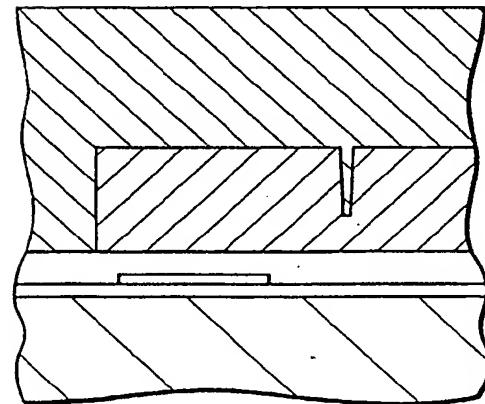


FIG. 8A

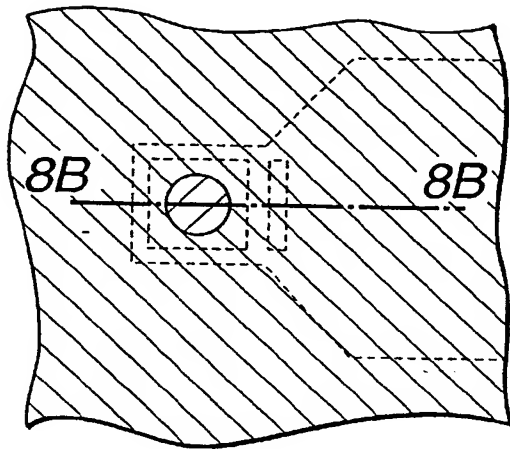


FIG. 8B

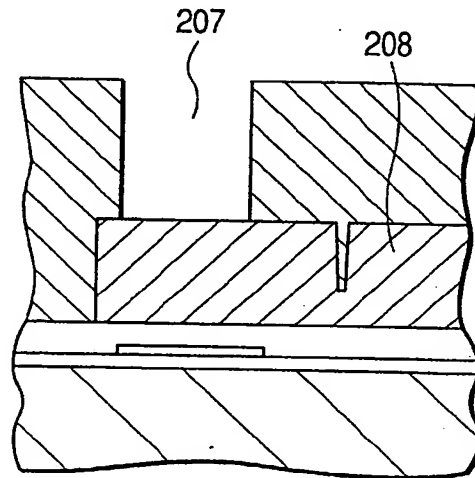


FIG. 8C

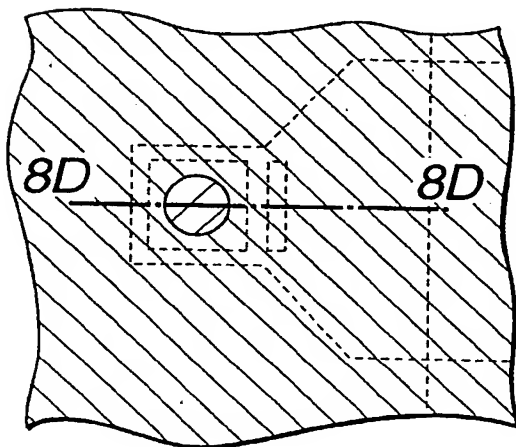


FIG. 8D

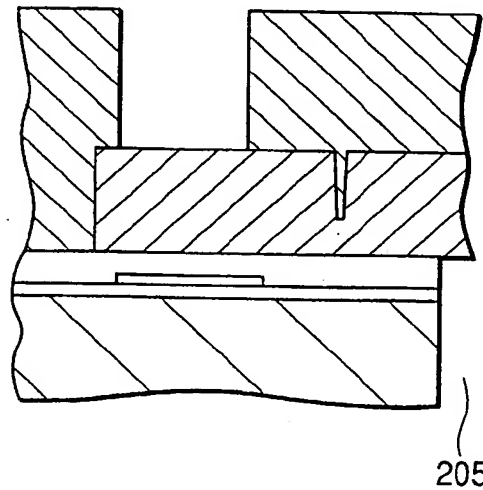


FIG. 9A

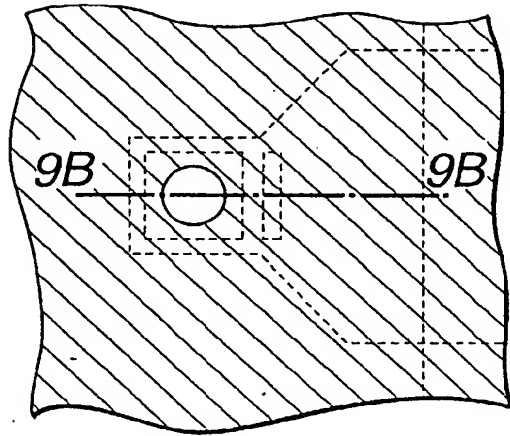


FIG. 9B

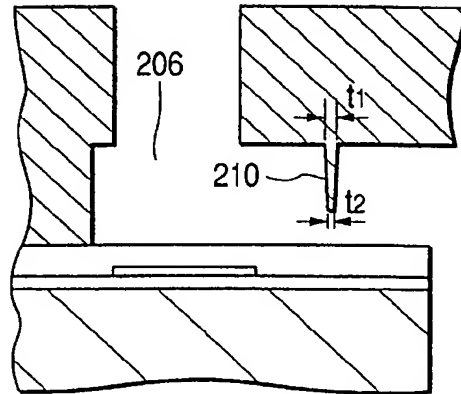


FIG. 10

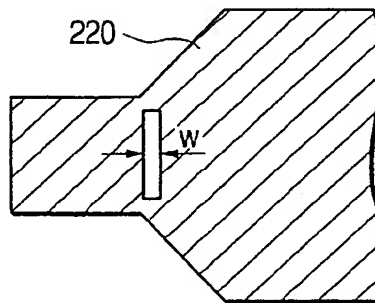


FIG. 11

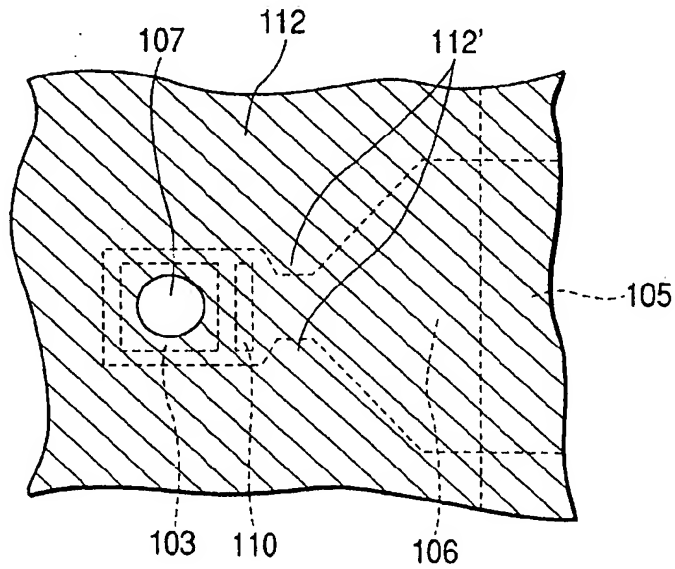


FIG. 12A

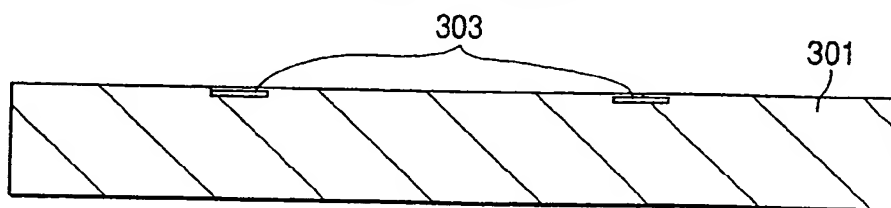


FIG. 12B

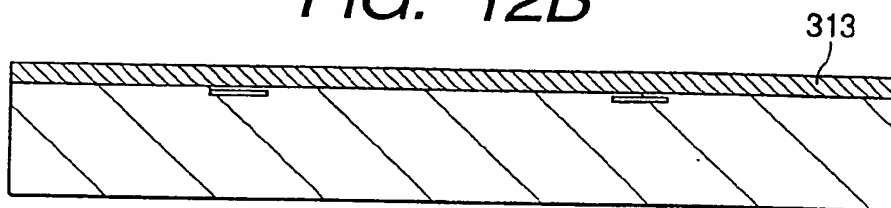


FIG. 12C

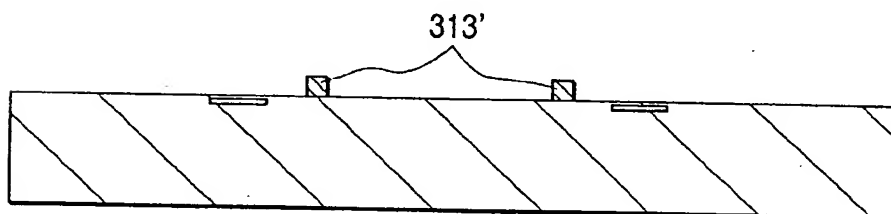


FIG. 12D

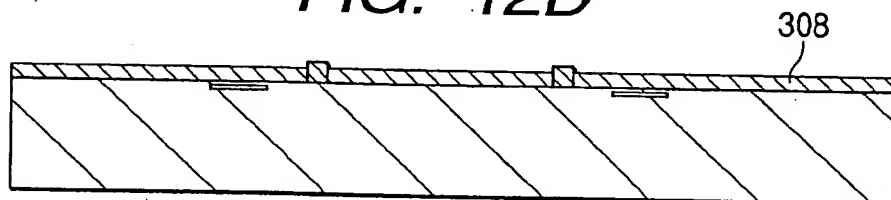


FIG. 12E

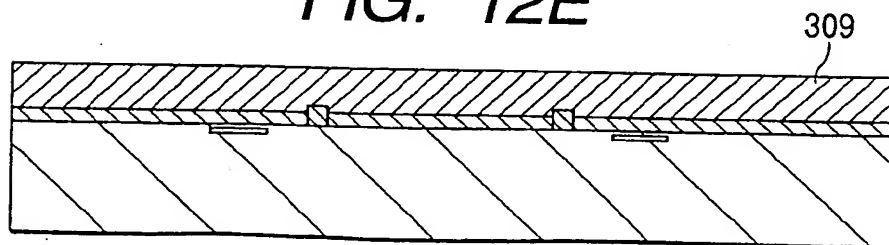


FIG. 13A

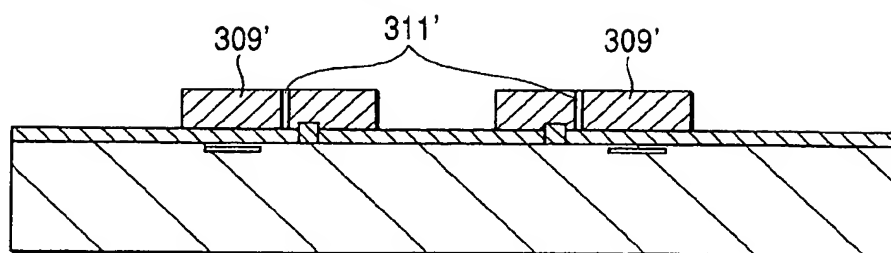


FIG. 13B

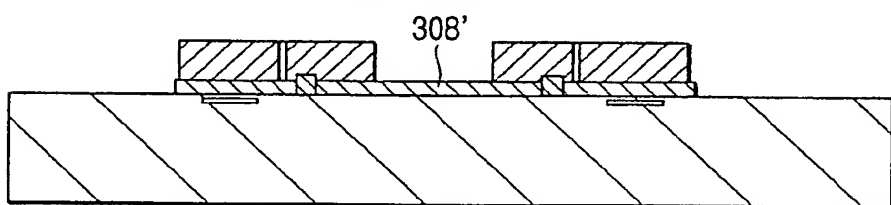


FIG. 13C

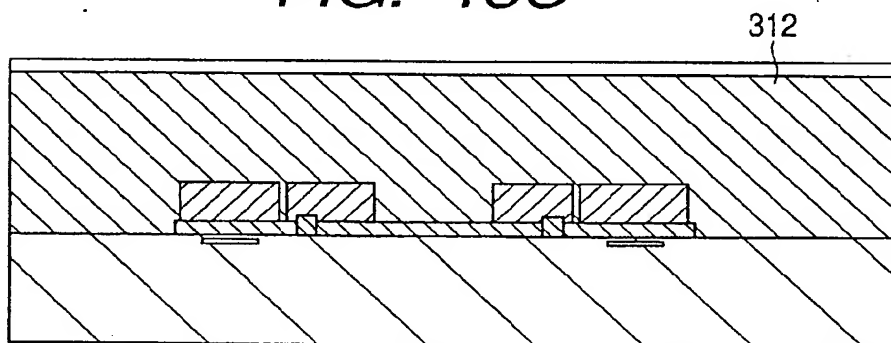


FIG. 13D

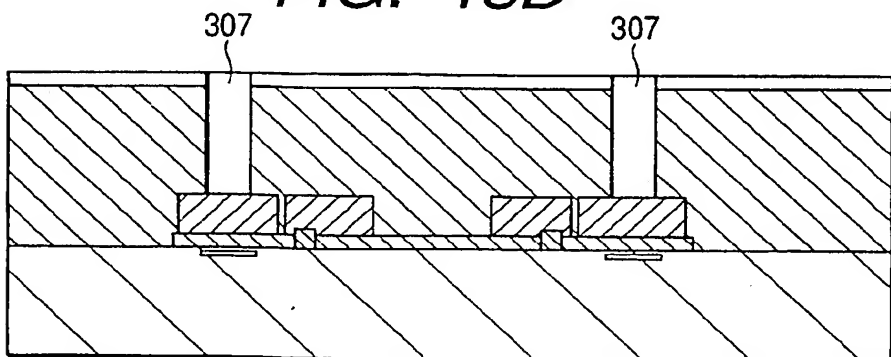


FIG. 14A

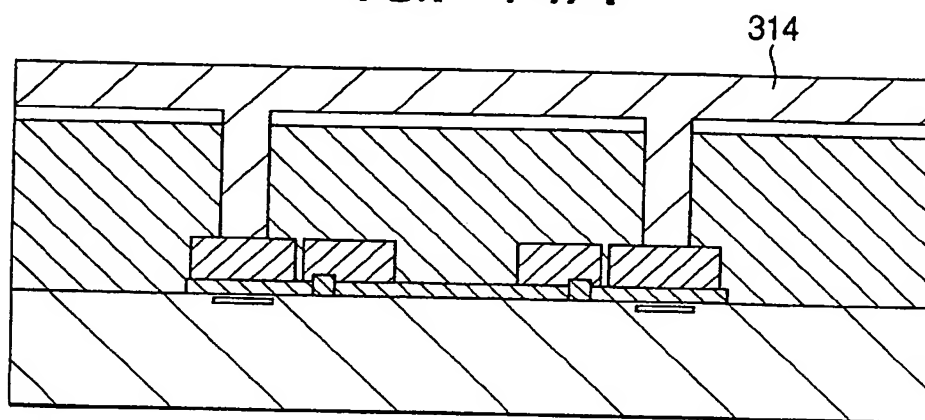


FIG. 14B

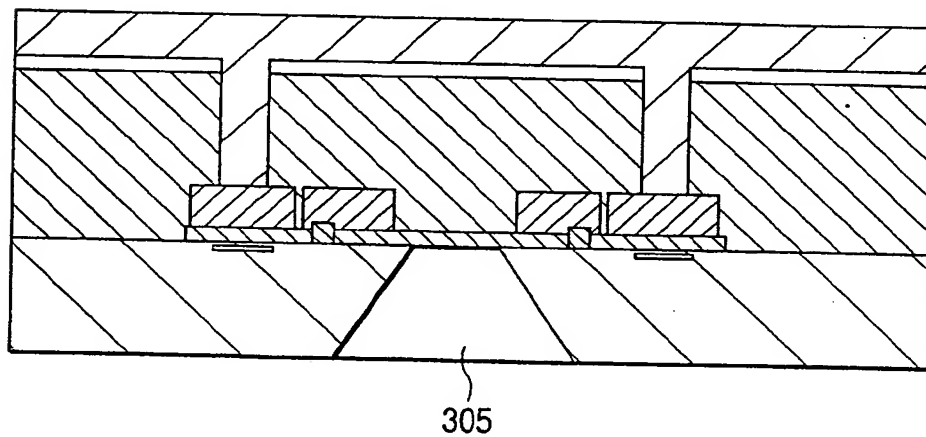


FIG. 14C

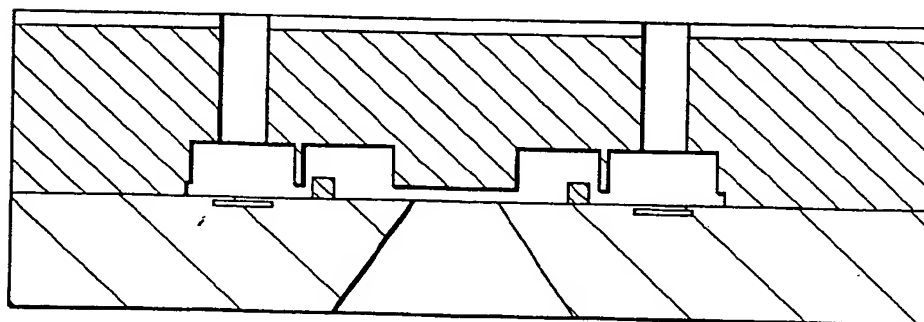


FIG. 15A

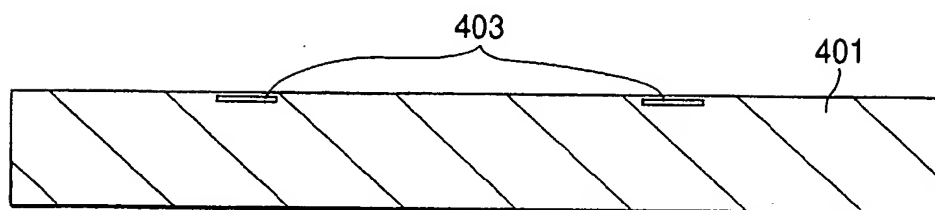


FIG. 15B

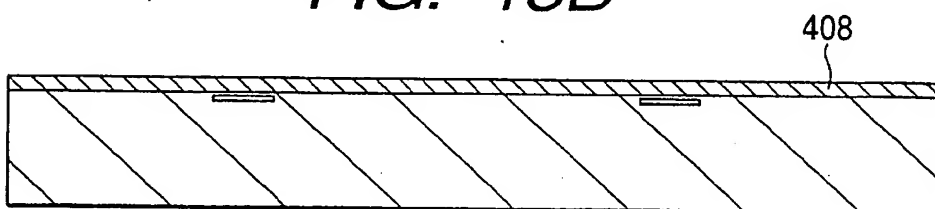


FIG. 15C

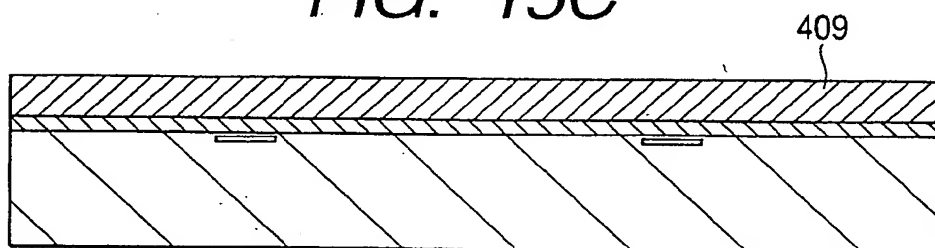


FIG. 15D

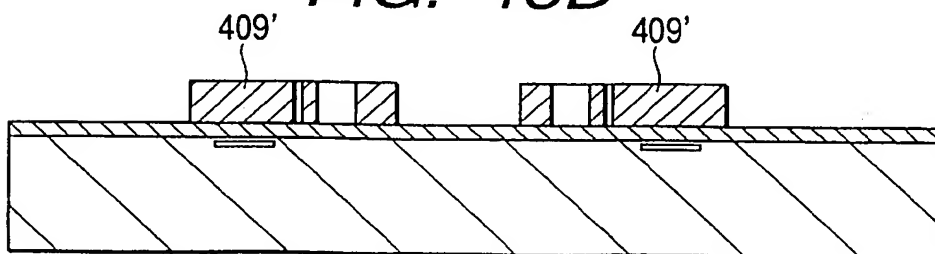


FIG. 16A

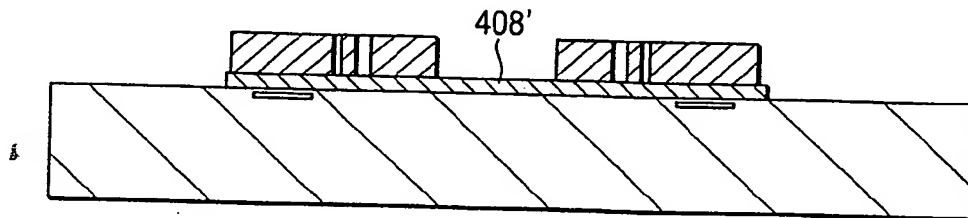


FIG. 16B

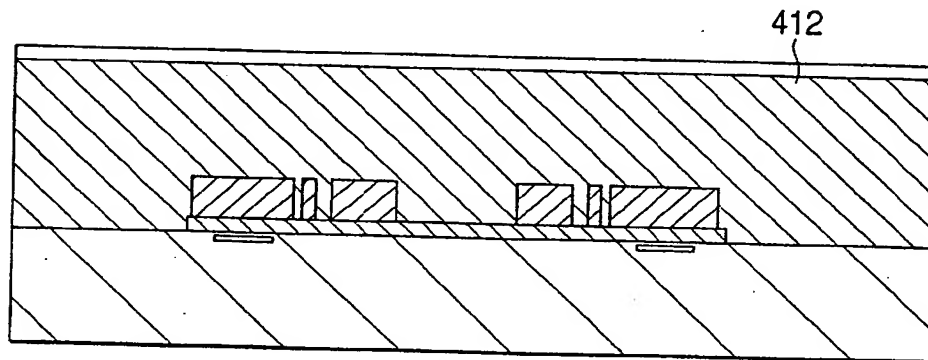


FIG. 16C

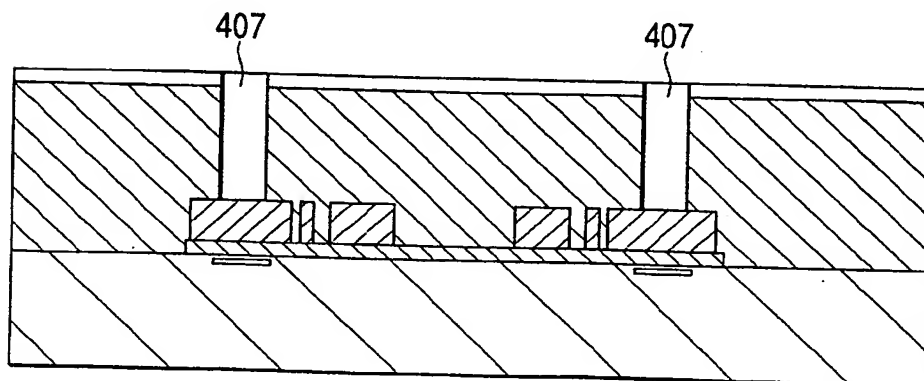


FIG. 17A

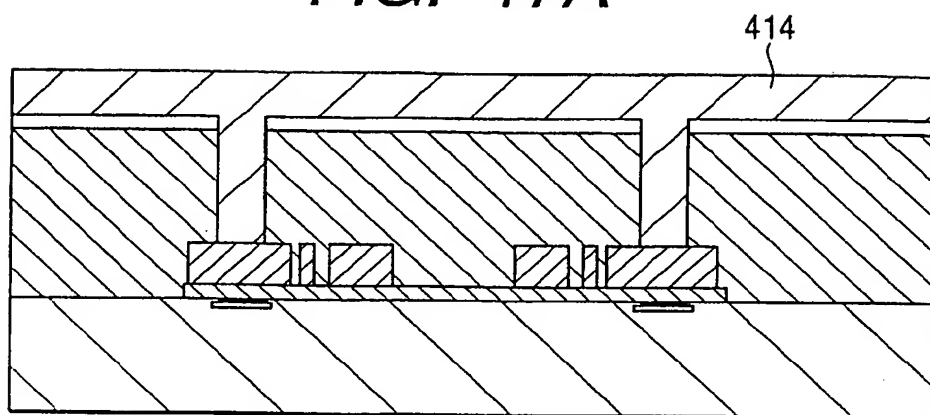


FIG. 17B

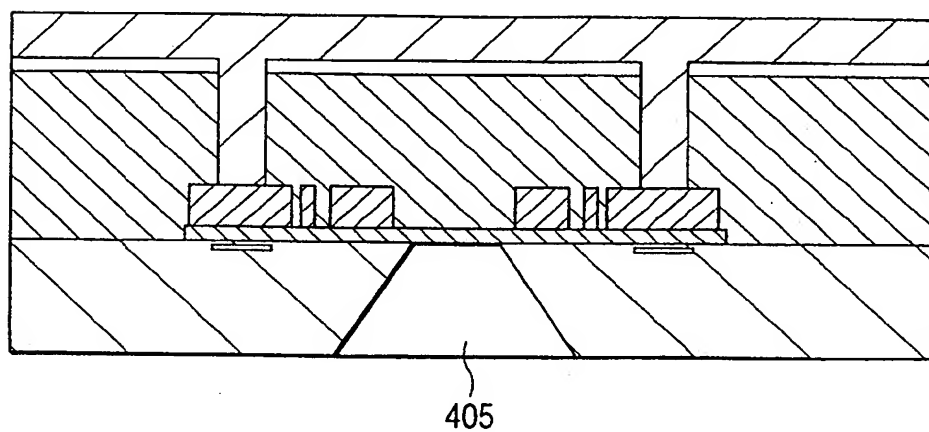


FIG. 17C

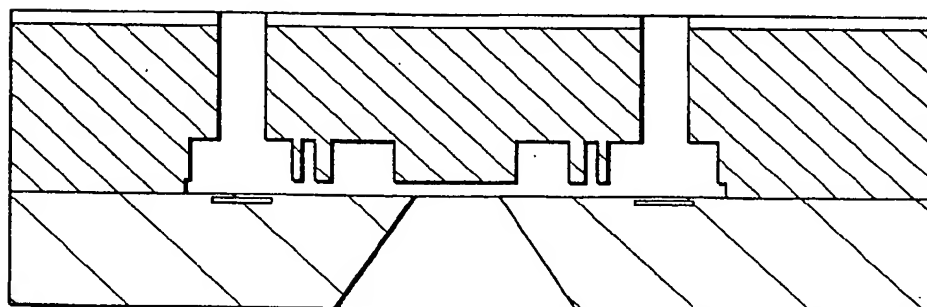


FIG. 18

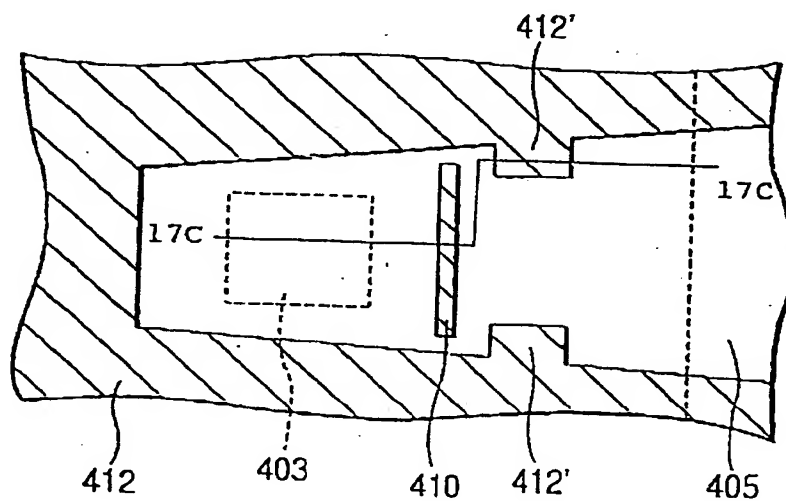


FIG. 19A

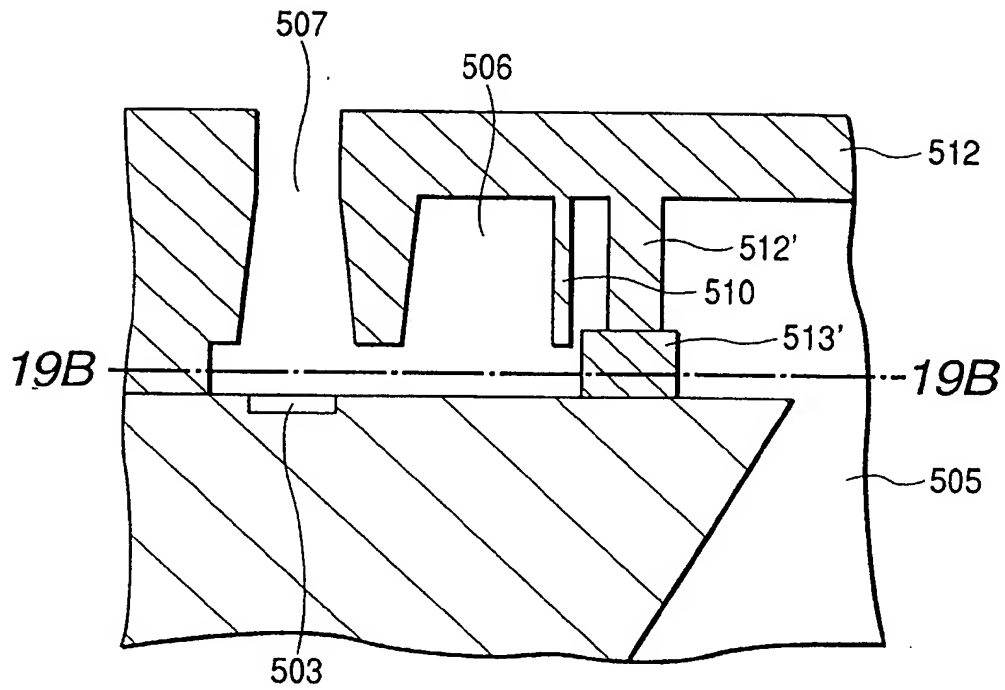


FIG. 19B

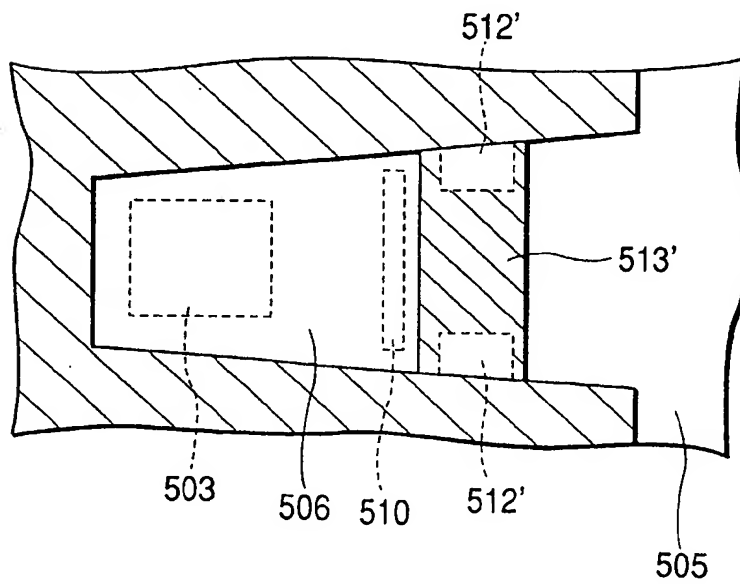


FIG. 20A

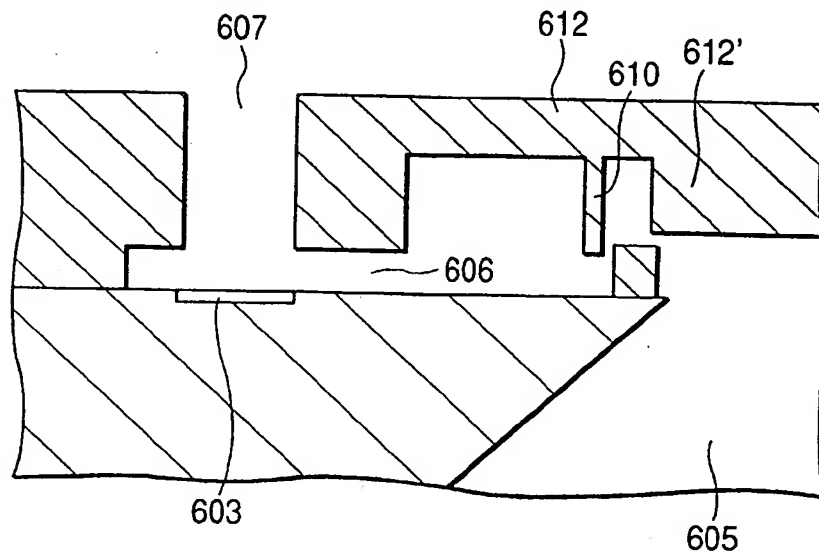


FIG. 20B

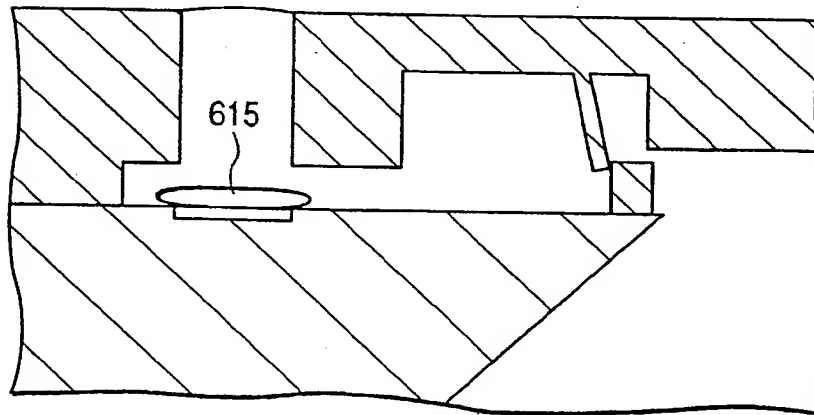


FIG. 21A

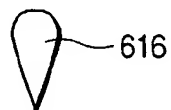
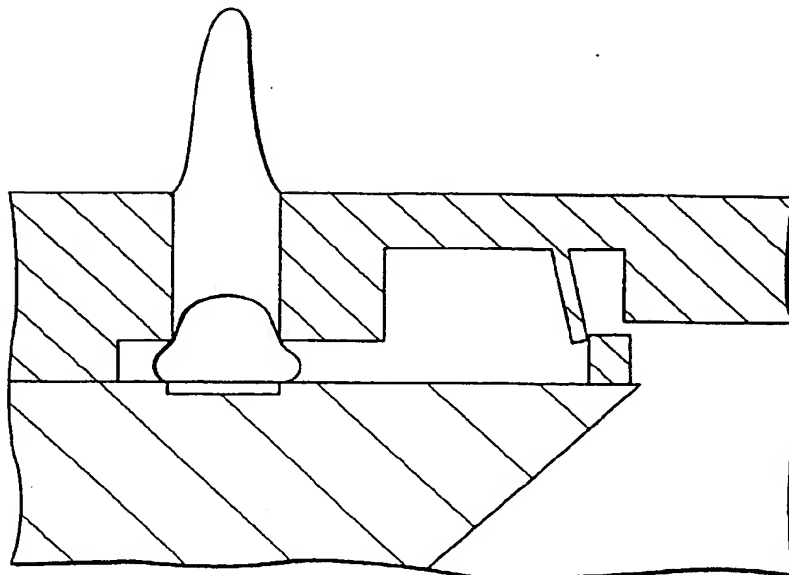


FIG. 21B

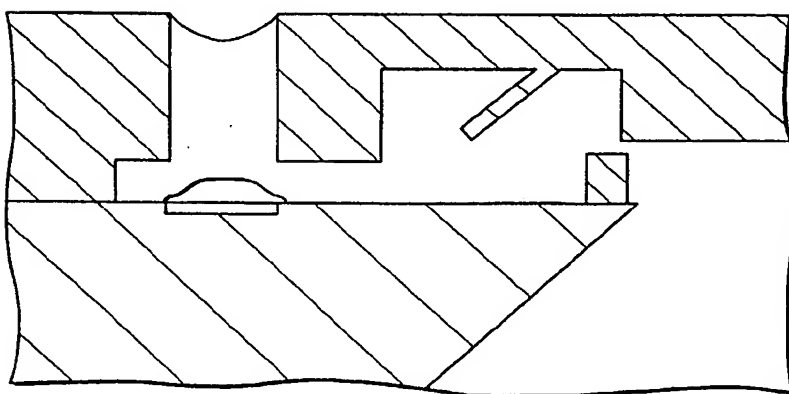
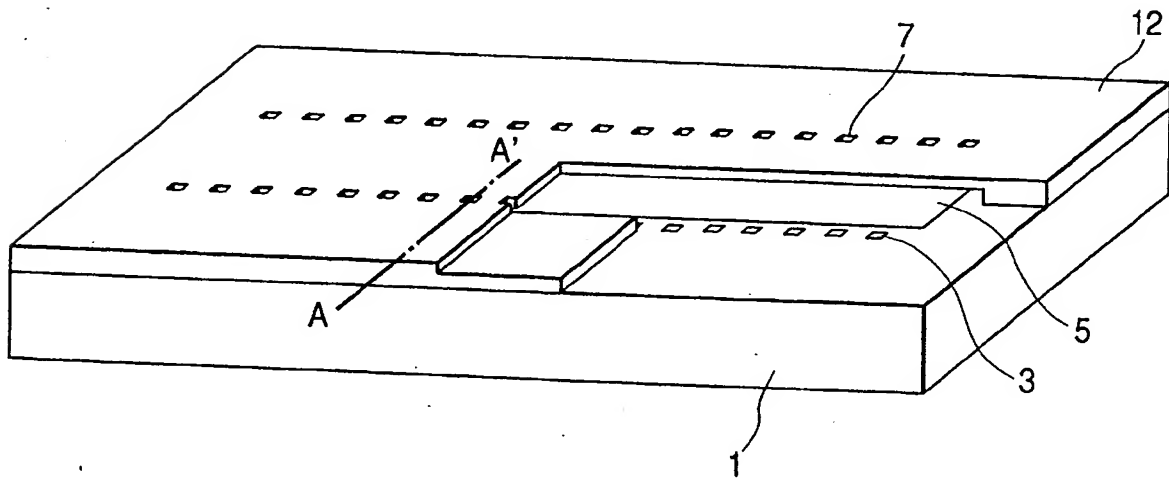
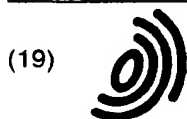


FIG. 22





(19)

Europäisches Patentamt
European Patent Office
Office européen des brevets



(11)

EP 1 283 109 A3

(12)

EUROPEAN PATENT APPLICATION

(88) Date of publication A3:
15.10.2003 Bulletin 2003/42

(51) Int Cl.7: **B41J 2/16, B41J 2/14**

(43) Date of publication A2:
12.02.2003 Bulletin 2003/07

(21) Application number: **02255582.5**

(22) Date of filing: **09.08.2002**

(84) Designated Contracting States:
**AT BE BG CH CY CZ DE DK EE ES FI FR GB GR
IE IT LI LU MC NL PT SE SK TR**
Designated Extension States:
AL LT LV MK RO SI

- **Misumi Yoshinori**
Tokyo (JP)
- **Kubota Masahiko**
Tokyo (JP)
- **Sugiyama Hiroyuki**
Tokyo (JP)
- **Inoue Ryoji**
Tokyo (JP)

(30) Priority: **10.08.2001 JP 2001243299**
25.07.2002 JP 2002216166

(71) Applicant: **CANON KABUSHIKI KAISHA**
Ohta-ku Tokyo 146-8501 (JP)

(74) Representative:
Beresford, Keith Denis Lewis et al
BERESFORD & Co.
2-5 Warwick Court,
High Holborn
London WC1R 5DH (GB)

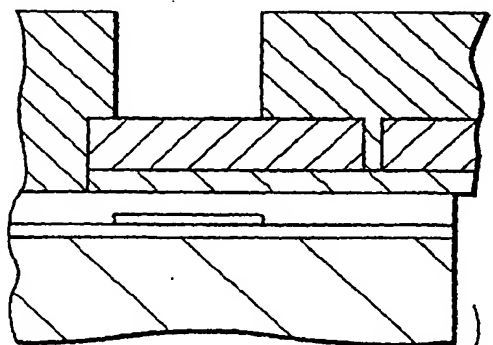
(72) Inventors:

- **Komuro Hirokazu**
Tokyo (JP)
- **Miyagawa Masashi**
Tokyo (JP)

(54) **Ink jet recording head and method for manufacturing the same**

(57) The present invention provides a method for manufacturing an ink jet recording head utilizing ink bubbling by heating of an exothermic resistor to thereby eject ink and a method manufacturing the same, including the steps of: preparing a substrate provided with the exothermic resistor; applying such first resin on the substrate as to provide a first mold shape for forming the nozzle channel and the movable member; forming the first mold shape using the first resin; applying, on the substrate, second resin over the first mold shape for forming the nozzle channel and the movable member; and removing the first mold shape. By this method, the movable member is formed in the nozzle channel between the ink inlet and the exothermic resistor to thereby provide a high-density, high-accuracy ink jet recording head which can improve a frequency response while maintaining proper discharge performance.

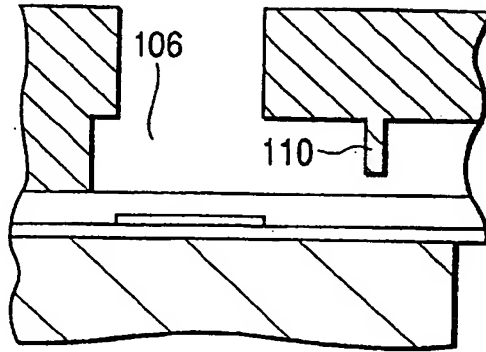
FIG. 4D



105

EP 1 283 109 A3

FIG. 5B





European Patent
Office

EUROPEAN SEARCH REPORT

Application Number
EP 02 25 5582

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.7)
A	EP 1 005 996 A (CANON KK) 7 June 2000 (2000-06-07) * abstract *	1-13	B41J2/16 B41J2/14
A	EP 1 057 642 A (CANON KK) 6 December 2000 (2000-12-06) * the whole document *	1-13	
A	EP 1 057 637 A (CANON KK) 6 December 2000 (2000-12-06) * the whole document *	1-13	
			TECHNICAL FIELDS SEARCHED (Int.Cl.7)
			B41J
The present search report has been drawn up for all claims			
Place of search MUNICH		Date of completion of the search 20 August 2003	Examiner Callan, F
<p>CATEGORY OF CITED DOCUMENTS</p> <p>X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document</p> <p>T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document</p>			

EPO FORM 1503 03.02 (P04C01)

**ANNEX TO THE EUROPEAN SEARCH REPORT
ON EUROPEAN PATENT APPLICATION NO.**

EP 02 25 5582

This annex lists the patent family members relating to the patent documents cited in the above-mentioned European search report. The members are as contained in the European Patent Office EDP file on
The European Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

20-08-2003

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
EP 1005996 A	07-06-2000	EP 1005996 A2	07-06-2000
		JP 2000225711 A	15-08-2000
		US 6468437 B1	22-10-2002
EP 1057642 A	06-12-2000	AU 3786200 A	07-12-2000
		CA 2311842 A1	04-12-2000
		CN 1276296 A	13-12-2000
		EP 1057642 A1	06-12-2000
		JP 2001047633 A	20-02-2001
		SG 84603 A1	20-11-2001
		US 6591500 B1	15-07-2003
EP 1057637 A	06-12-2000	JP 2000343707 A	12-12-2000
		AU 3783900 A	07-12-2000
		CA 2309232 A1	04-12-2000
		CN 1276294 A	13-12-2000
		EP 1057637 A2	06-12-2000
		US 6513911 B1	04-02-2003

EPO FORM P0459

For more details about this annex : see Official Journal of the European Patent Office, No. 12/82